



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **HASHIMOTO, Hiroshi et al.**

Serial No.: 09/960,399

Group Art Unit: 2814

Filed: September 24, 2001

Examiner: Howard Weiss

P.T.O. Confirmation No.: 5652

For. **A SEMICONDUCTOR INTEGRATED CIRCUIT AND FABRICATION PROCESS  
HAVING COMPENSATED STRUCTURES TO REDUCE MANUFACTURING DEFECTS  
(as amended)**

REQUEST FOR APPROVAL OF DRAWING CHANGES

Commissioner for Patents  
Washington, D.C. 20231

*#8/Dwgs.  
Morgan  
10/8/02  
October 1, 2002*

Sir:

The Examiner's approval of the drawing corrections indicated in red ink on the attached 51 sheets of drawings is respectfully requested.

Upon receipt of approval of the drawing corrections and a formal Notice of Allowance, a bonded draftsman will be retained and the appropriate corrections will be made.

In the event any fees are required in connection with this paper, please charge our Deposit Account No. 01-2340.

Respectfully submitted,  
ARMSTRONG, WESTERMAN & HATTORI, LLP

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GNS/alw

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Attachment: 51 Sheets of Corrected Drawings